

FORM PTO-1449 (Equivalent)

U.S. Department of Commerce Patent and Trademark Office

U.S. Application Serial No. 09/740,146

Atty. Docket No. AM-3396.D1

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Anisul Khan et al. **Applicants**

December 18, 2000

Filing Date

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			U.S. PATENT DOCU	MENTS		
Examiner Initial	Document Number	Issue Date	Name	Class	Subclass	Filing Date If Appropriate
Atral	5,431,772	07/11/95	Babie et al.	156	643.1	
			FOREIGN PATENT DO	CUMENTS		
Examiner Initial	Document Number	Publicati <u>Date</u>	on Name	Cla ss	Set	K Appropriate
ARCY	EP 0 854 5 10	0 07/22/9	8 Muller et al.	HOTE	21/8249	
gref.	JP 8017804	01/19/9	6 SONY CORP.	HOOPL	030/3085	Adstract
	ОТНЕ	R DOCUME	NTS (Including Author, T	itle, Date, Perti	nent Pages, e	tc.)
Copy of a S	earch Report i	n correspond	ing EP Application No. EI	P 00120681.2-2	203, dated Se	eptember 22, 2002.
Examiner		Date Co	onsidered			
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George Goudrean Examiner: Initial if Cation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

U. S. PATENT DOCUMENTS

Examiner Initial	Document Number	Issue Date	Name	Class	Subclass	Filing Date If Appropriate
OIPE	5,423,941	, 06/13/95	Komura et al.***	156	643.1	
DEC 3 0 2012	5,585,012	12/17/96	Wu et al.*	216	71	
TENTE TRANSPORT	5,756,400	05/26/98	Ye et al.*	438	710	
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FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Publication <u>Date</u>	Name	€±as s	Superiss	Appropriate
900	WO 99/20812	04/29/99	Yin et al.**	Œ	10/4	
9120X	WO 99/25,015	05/20/99	Qian Xue-Yu et al.****	₩ L	24/3243	·

Examiner Date Considered

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^{*} Provided by applicant in prosecution of parent application, U.S. Serial No. 09/405,349, as issued on November 20, 2001, U.S. Patent No. 6,318,384 B1.

^{**} Cited by Examiner in prosecution of parent application, U.S. Serial No. 09/405,349, as issued on November 20, 2001, U.S. Patent No. 6,318,384 B1.

^{***} Cited in a counterpart foreign application.

^{****} Cited by Examiner in prosecution of parent application, U.S. Serial No. 09/405,349, as issued on November 20, 2001, U.S. Patent No. 6,318,384 B1. The Examiner has also cited EP 1,029,345 to Qian Xue-Yu et al., which has matured into WO 9925015. Therefore, EP 1,029,345 is not included as a reference.

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

Yan Ye et al., "0.35-Micron and Sub-0.35-Micron Metal Stack Etch in a DPS Chamber — DPS Chamber and Process Characterization," Electrochemical Society Proceedings, Vol. 96-12, (1996). pp. 222-233.

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FORM PTO-1445 TRADES (Equivalent)

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U. S. PATENT DOCUMENTS

Examiner Initial	Document Number	Issue Date	Name	Class	Subclass	Filing Date If Appropriate
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0/0	4,668,338	05/26/87	Maydan et al.	156	643	
	4,842,683	06/27/89	Cheng et al.	156	345	RECEIVED
	4,951,601	08/28/90	Maydan et al.	118	719	TOEIVED
+		-	Toshima et al.	414	217	
949	5,298,790	03/29/94	Harmon et al.***	257	622	1700

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